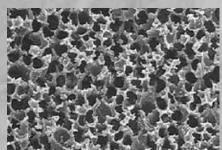
Polishing Pads

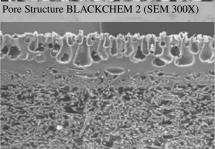
ANDFINISH

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Polishing pads are classified as either non-woven and woven. Woven polishing pads are fiber woven textile cloths, whereas, non-woven pads are polymetric pads which typically have a porous structure.

NANOFINISH Corporation offers a wide selection of woven and non-woven polishing pads for industrial polishing operations. Our woven products include our low napped DACRON and POLYPAD pads, as well as our high napped MICROPAD.



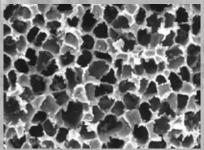


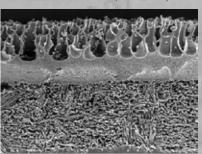
Cross Section for BLACKCHEM 2 (SEM 100X)

The non-woven products include our PC urethane impregnated polishing pads as well as our more chemically resistant BLACKCHEM 2 polishing pad.

Our polishing pads offer an affordable alternative to competitive products from company's such as RODEL.

BLACKCHEM 2 is a replacement polishing pad for the POLITEX polishing pad (see comparision table below). Its main application





Cross Section for POLITEX (SEM 100X)

NANOFINISH Blackchem 2	RODEL POLITEX
1.369	1.471
583.1	582.6
66	61
67.8 94.33	62.9 96.8
1.3	n.a.
68.6	78.1
40.6	55
	Blackchem 2 1.369 583.1 66 67.8 94.33 1.3

POLISHING PADS

-Semiconductor Wafers -Optical Components -Magnetic Wafers





NANOFINISH Replaces Specific Durometer Thickness Max size Gravity Hardness PC80 **SUBA 500** 0.58 <C80 0.050" - 1" 39.5" x 39.5" SUBA V PC60 040 >C60 0.005" - 1" 39.5" x 39.5" PC40 SUBA IV / 0.34 C40 0.90" - 1" 53" x 53" **B60** PC55-LD SUBA X 0.32 C55 0.050" - 1" 39.5" x 39.5" **B75** PC55-HD SUBA X 0.42 C55 0.050" - 1" 39.5" x 39.5" **B75** C20 PC20 Natural wool 0.31 1/8" - 1" 53" x 53" B75

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is for CMP polishing with alumina or colloidal silica. The BLACKCHEM 2 also has a very similar and porous structure as the POLITEX pad.

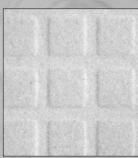
Impregnated Felt Polishing Pads

The PC series of polishing pads are urethane impregnated polishing pads. They are alternative polishing pads for the SUBA series of polishing pads (see following comparison table). The main polishing applications for these pads are for glass, ceramics, precision optics and other materials where surface finish is critical.

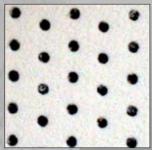
Woven Polishing Pads

The DACRON and POLYPAD polishing pads have a low napped woven polishing design as shown below. These pads are very durable and are excellent polishing pads for intermediate sized diamond, silicon carbide, ceria, or alumina polishing slurries.

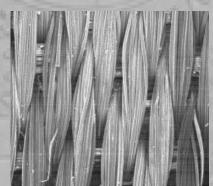
The MICROPAD final polishing pad is a high napped or flocked polishing pad. It produces a relatively gentle polishing action and is very useful for polishing metals and other soft materials.



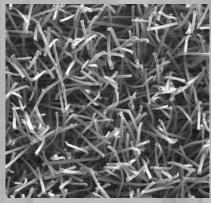
PC60 Embossed Polishing Pad



PC60 Perforated Polishing Pad



DACRON woven polishing pad



MICROPAD high napped polishing pad